

# (19) United States

# (12) Patent Application Publication (10) Pub. No.: US 2024/0237543 A1 APALKOV et al.

## Jul. 11, 2024 (43) **Pub. Date:**

### (54) PERPENDICULAR SHAPE ANISOTROPY **DESIGN WITH REDUCED AEX**

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(21) Appl. No.: 18/116,839

(22) Filed: Mar. 2, 2023

### Related U.S. Application Data

(60) Provisional application No. 63/437,359, filed on Jan. 5, 2023.

### **Publication Classification**

(51) Int. Cl. H10N 50/10 (2006.01)G11C 11/16 (2006.01)

H01F 10/32 (2006.01)H10B 61/00 (2006.01)H10N 50/85 (2006.01)

(52)U.S. Cl.

> CPC ...... H10N 50/10 (2023.02); G11C 11/161 (2013.01); H01F 10/3286 (2013.01); H10B 61/00 (2023.02); H10N 50/85 (2023.02)

#### (57)ABSTRACT

A perpendicular shape anisotropy magnetic tunnel junction structure includes a reference layer, a non-magnetic layer, and a free layer. The reference layer includes a first side and a second side that is opposite the first side of the reference layer. The non-magnetic spacer includes a first side and a second side in which the first side of the non-magnetic spacer is on the second side of the first reference layer. The free layer includes a first side and a second side in which the first side of the free layer is on the second side of the non-magnetic spacer and in which the free layer further includes an exchange energy  $A_{ex}$  having a range of 0.5 to 1.0 μerg/cm<sup>2</sup>.

